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		FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
APPLICATION NO.	FILING DATE		19519-302	9431
10/0/0 407	05/23/2001	Noriaki Watanabe	17017 01-	

09/862,497

05/23/2001

03/18/2003

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EXAMINER CHU, JOHN S Y

PAPER NUMBER ART UNIT

1752

DATE MAILED: 03/18/2003

Please find below and/or attached an Office communication concerning this application or proceeding.

		Application No	).	Applicant(s)
•		09/862,497		WATANABE ET AL.
. Office Action Summary		Examiner		Art Unit
		John S. Chu		1752
	The MAILING DATE of this communication app	pears on the cov	er sh	eet with the correspondence address
ariad for	Renly			
THE M - Extens after S - If the p - If NO p	PRTENED STATUTORY PERIOD FOR REPLIALING DATE OF THIS COMMUNICATION. Sions of time may be available under the provisions of 37 CFR 1.1 IX (6) MONTHS from the mailing date of this communication. Period for reply specified above is less than thirty (30) days, a reploeriod for reply is specified above, the maximum statutory period to reply within the set or extended period for reply will, by statute ply received by the Office later than three months after the mailing patent term adjustment. See 37 CFR 1.704(b).	136(a). In no event, ho ly within the statutory will apply and will exp	wever, ninimur re SIX (	may a reply be timely filed  m of thirty (30) days will be considered timely.  (6) MONTHS from the mailing date of this communication.
tatus		May 2001		
1)🛛	Responsive to communication(s) filed on 23		final	1
2a)□	This action is <b>FINAL</b> . 2b)⊠ 1	his action is nor	-IIIIai	ool matters, prosecution as to the merits is
3)	Since this application is in condition for allow closed in accordance with the practice under	r Ex parte Quay	le, 19	935 C.D. 11, 453 O.G. 213.
	on of Claims	1.		
4)⊠	Claim(s) <u>2-4</u> is/are pending in the application 4a) Of the above claim(s) is/are withdra	 awn from consid	derati	ion.
	Claim(s) 3 and 4 is/are allowed.			
	Claim(s) 2 is/are rejected.			
7)[	Claim(s) is/are objected to.  Claim(s) are subject to restriction and	or election real	irem	ent.
	ion Papers	,0,0,0,000,000,000		
	The specification is objected to by the Examir	ner.		
40)	The drawing(s) filed on is/are: a) acc	cepted or b)□ ob	jected	d to by the Examiner.
	Applicant may not request that any objection to	the drawing(s) be	held	in abeyance. See 37 CFR 1.65(a).
11)	The proposed drawing correction filed on	is: a)□ app	roved	d b)  disapproved by the Examiner.
11/	If approved, corrected drawings are required in	reply to this Offic	e actio	on.
12)	The oath or declaration is objected to by the			
Priority	under 35 U.S.C. §§ 119 and 120			
13)⊠	Acknowledgment is made of a claim for fore	eign priority und	er 35	U.S.C. § 119(a)-(d) or (f).
	)⊠ All b)□ Some * c)□ None of:			
	1 Certified copies of the priority docume	ents have been	recei	ived.
	2 ☑ Certified copies of the priority docume	ents have been	recei	ived in Application No. <u>09/287,568</u> .
	3. Copies of the certified copies of the p	oriority documer	ts ha	ve been received in this National Stage 7.2(a)).
*	See the attached detailed Office action for a	list of the certifi	tor 21	FUSC 8 119(e) (to a provisional application).
14)	Acknowledgment is made of a claim for dom	estic priority uni	dicati	5 U.S.C. § 119(e) (to a provisional application).
15)[	a)  The translation of the foreign language Acknowledgment is made of a claim for dom	provisional app nestic priority un	der 3	5 U.S.C. §§ 120 and/or 121.
Attachm			, <b></b>	Interview Summary (PTO-413) Paper No(s)
2) NO	otice of References Cited (PTO-892) otice of Draftsperson's Patent Drawing Review (PTO-948) formation Disclosure Statement(s) (PTO-1449) Paper No	,	4)     5)     6)	Notice of Informal Patent Application (PTO-152)  Other:
U.S. Patent ar	nd Trademark Office	as Action Summar		Part of Paper No. 4

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#### **DETAILED ACTION**

This Office action is in response to the application filed May 23, 2001.

### Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(e) the invention was described in-

(1) an application for patent, published under section 122(b), by another filed in the United States before the invention by the applicant for patent, except that an international application filed under the treaty defined in section 351(a) shall have the effect under this subsection of a national application published under section 122(b) only if the international application designating the United States was published under Article 21(2)(a) of such treaty in the English language; or

(2) a patent granted on an application for patent by another filed in the United States before the invention by the applicant for patent, except that a patent shall not be deemed filed in the United States for the purposes of this subsection based on the filing of an international application filed under the treaty defined in section 351(a).

Claims 2 is rejected under 35 U.S.C. 102(e) as being clearly anticipated by KAWAMURA et al '640.

The claimed invention is drawn to a photosensitive resin composition containing a high molecular compound having at least the constituting component represented by formulae (1), (2) and (3) sa copolymer components, and o-quinonediazide compound:

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#### CH2=CA[COO-R'-Rs]

(1)

(2)

wherein A represents a hydrogen atom or a methyl group; R' represents a single bond,  $-(CH_2)_m-,-(CH_2)_mNR^mSO_2-,$  or  $-(CH_2)_mNR^mCO-;$  m represents an integer of from 1 to 4; R'' represents a hydrogen atom or an alkyl group;  $R_d$  represents  $C_nF_{m+1}$ ; and n represents an integer of 3 or more;

## CH2-CA[CO-F-R2-SO,NH-R4]

wherein A represents a hydrogen stom or a methyl group; W represents an oxygen atom or -NR<sub>3</sub>-; R<sub>3</sub> represents a hydrogen atom, an alkyl group, or an aryl group; R<sub>4</sub> represents an alkylene group or an arylene group, each of which may have a substituent; and R<sub>2</sub> represents a hydrogen atom, an alkyl group, or an aryl group;

## $CH_{2}=CA\left[CO-N-R_{2}\right] \tag{3}$

wherein A represents a hydrogen atom or a methyl group; W represents an oxygen atom or  $-NR_k-$ ; R, represents a hydrogen atom, an alkyl group, or an aryl group; and R<sub>k</sub> represents an aliphatic group having 9 or more carbon atoms, or an aromatic group substituted with an aliphatic group having 2 or more carbon atoms.

KAWAMURA et al anticipates the claimed invention at Examples 2B, 5B, 8B, 11B as seen in Tables 1B, 4B, 6B, 8B, 9B, respectively. The polymer used in those Examples is P<sub>1</sub>-12 which anticipates the copolymer of claim 2.

3. Claims 3 and 4 are allowed.

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The claims are further drawn to a photosensitive lithographic printing plate comprising a support having coated thereon a photosensitive layer containing the following components (a), (b) and (c),

- (a) an o-naphthoquinonediazide compound
- (b) a resin soluble in an alkaline aqueous solution, and
- (c) a polymer having a (meth)acrylate monomer having two or three perfluoroalkyl groups having from 3 to 20 carbon atoms in the molecule as a polymer component.
- 4. None of the prior art references of record disclose the claimed lithographic printing plate having the polymer of ingredient (c) in a photosensitive layer with ingredients (a) and (b).

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. HIGASHINO et al. is cited of interest for teaching a lithographic printing plate having a quinonediazide compound, a novolak and a polymer, however this polymer fails to meet the claimed polymer in claims 3 and 4.

KAWAUCHI et al is the patent to the parent application 09/287,568.

5. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Examiner Chu whose telephone number is (703) 308-2298. The examiner can normally be reached on Monday - Friday from 9:30 am to 6:00 pm.

The fax phone number for this Group is (703) 305-7718.

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Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the Group receptionist whose telephone number is (703) 308-0661.

ohn S. Chu

Primary Examiner, Group 1700

J.Chu

March 11, 2003